

INFORMATION DISCLOSURE  
CITATION

ATTY. DOCKET NO.

SERIAL NO.

340-80

10/686,520

APPLICANT

KOCHERGIN et al.

FILING DATE

TC/A.U.

16 October 2003

2872 2883

## U.S. PATENT DOCUMENTS

INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
Cmk	4,874,484	10/1989	Foell et al.	438	750	
A	5,262,021	11/1993	V. Lehmann et al.	205	655	
	5,348,627	09/1994	Propst et al.	205	655	
	5,431,766	07/1995	Propst et al.	156	345.15	
	5,544,772	08/1996	Soave et al.	216	2	
	5,645,684	07/1997	Keller	148	33.2	
	5,987,208	11/1999	Grunig	385	148	
	5,997,713	12/1999	Beetz, Jr. et al.	205	124	
	6,521,149	02/2003	Mearini et al.	264	81	
Cmk	6,526,191	02/2003	Geusic et al.	385	14	

## FOREIGN PATENT DOCUMENTS

DOCUMENT	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES NO
3717851		Germany			
Cmk 4202454		Germany			

## OTHER DOCUMENTS (including Author, Title, Date, Pertinent pages, etc.)

Cmk	Lehmann et al., Optical shortpass filters based on macroporous silicon <i>Appl. Phys. Lett.</i> V 78, N.5, Jan. 2001.
Cmk	J. Schilling et al., "Three-dimensional photonic crystals based on Macroporous silicon with modulated pore diameter", <i>Appl. Phys. Lett.</i> V 78, N.9, Feb. 2001
Cmk	S. Izuo et al., "A novel electrochemical etching technique for n-type silicon," <i>Sensors and Actuators A</i> 97-98 (2002), pp. 720-724
Cmk	A. Vyatkin et al., "Random and Ordered Macropore Formation in p-Type Silicon," <i>J. of the Electrochem. Soc.</i> , 149 (1), pp. G70-G76 (2002)
	H. Föll et. al, "Formation and application of porous silicon", <i>Mat. Sci. Eng. R</i> 39 (2002), pp. 93-141

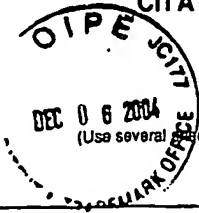
\*Examiner

Date Considered

Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to application.



**INFORMATION DISCLOSURE  
CITATION**



(Use several sheets if necessary)

ATTY. DOCKET NO.

340-80

**APPLICANT**

KOCHERGIN et al.

FILING DATE

16 October 2003

**SERIAL NO.**

10/686,520

TC/A.U.

28722883

## U.S. PATENT DOCUMENTS

[illegible]

## FOREIGN PATENT DOCUMENTS

[illegible]

**OTHER DOCUMENTS** (including Author, Title, Date, Pertinent pages, etc.)

[illegible]

**\*Examiner**

Chris Kalwood

**Date Considered**

1-18-05

Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to application.

**INFORMATION DISCLOSURE  
CITATION**

ATTY. DOCKET NO.

SERIAL NO.

340-80

10/686,520

**APPLICANT**

BOCHERGIN et al.

FILING DATE

16 October 2003

TC/A.U.

~~2872~~ 2883

## U.S. PATENT DOCUMENTS

[illegible]

## FOREIGN PATENT DOCUMENTS

[illegible]

**OTHER DOCUMENTS** (including Author, Title, Date, Pertinent pages, etc.)

[illegible]

**\*Examiner**

Chris Valwood

Date Considered

1-18-05

Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to application.